

Shielding And Insulating Argon Gas For Industrial And Medical Application

Basic Information

. Place of Origin: China . Brand Name: CMC COA · Certification: Model Number: Ar 1kg • Minimum Order Quantity: • Price: US \$15/kg · Packaging Details: Cylinder/Tank • Delivery Time: 15 days Payment Terms: L/C, T/T . Supply Ability: 5000kg/month



Product Specification

Product Name: Argon Gas
Cylinder Standard: DOT/ISO/GB
Boiling Point: -185.7 C
Melting Point: -189.2 C
Density: 1.784 Kg/M³
Transport Package: Sea Transportation
Specification: 10L 40L 47L 50L 200L

• Trademark: CMC

Origin: Suzhou, China
HS Code: 2804290000
Supply Ability: 2000piece/Month
CAS No.: 7440-37-1
Formula: Ar
EINECS: 231-147-0
Constituent: Industrial Pure Air



Argon Gas

Product Description

Product Description

Argon gas is a chemical element that belongs to the noble gases group on the periodic table. It is represented by the symbol "Ar" and has an atomic number of 18. Argon is a colorless, odorless, and tasteless gas that is found in small amounts in the Earth's atmosphere.

Argon is known for its inertness and is considered a noble gas because it tends not to react with other elements under normal conditions. It has a variety of industrial and scientific applications due to its unique properties. Some common uses of argon gas include:

Welding: Argon is commonly used as a shielding gas in various welding processes, such as Tungsten Inert Gas (TIG) welding and Gas Metal Arc Welding (GMAW). It helps protect the welding area from atmospheric contamination.

Lighting: Argon is often used in fluorescent lights, neon signs, and other gas-discharge lamps. When electrically charged, argon emits a faint blue-purple glow.

Insulation: Argon is sometimes used as an insulating gas in double-paned windows. Its low thermal conductivity helps reduce heat transfer through the windows, improving energy efficiency.

Scientific research: Argon is used in various scientific experiments and research applications. It can be used as a carrier gas in gas chromatography, as a blanketing gas in analytical instruments, and as a protective atmosphere for handling sensitive materials.

These are just a few examples of the many applications of argon gas. Its inert nature and unique properties make it suitable for various industrial, scientific, and technological purposes.

Basic Info.

Model NO. Ar Content Content: 28tons

Industrial Grade Industrial Grade Tank Car 26m

Purity 100.00% Transport Package Sea Transportation

Specification Tank Car: 26m3; Content: : 28tons Trademark CMC

Origin suzhou Production Capacity 5000 piece/Month

Product Parameters

Specification Tank Car:26m3 Content: 28tons

1. used as a protective gas for the production of high purity silicon and germanium crystals in the semiconductor industry;

Application 2.used as inert gas for system cleaning, shielding and pressurization;

3. Be applied in chemical vapor deposition, sputtering, annealing and other processes.

4. used as chromatographic carrier gas, and can also be used as a dilution gas of gas mixture in large-scale integrated circuits.

Detailed Photo



Company Profile



Shanghai Kemike Chemical Co., Ltd is staffed by trained personnel, combine many years experience in Gas industry .We supply cylinder gas, electronic gas, etc., and the gas holder, panel, valves and fittings and other equipment, parts and engineering services to our customers in China and worldwide; The products are involved in various industrial fields, such as semiconductor chip, solar cell, LED, TFT-LCD, optical fiber, glass, laser, medicine, etc., Our mission is to partner with our

global customers to provide support, solutions and quality products that are innovative, reliable, and safe. Our products mainly include: H2, O2, N2, Ar, CO2, propane, acetylene, helium, laser mixed gas, SiH4, Sih2cl2, SiHCL3, SiCL4, NH3, CF4, NF3, SF6, HCL, N2O, doping mixed gas (TMB, PH3, B2H6) and other electronic gases.

SiCI4 NH3 CH3F SiH4 H₂S WF6 F6+CI2 NH3 Kr HCI+Ne C3F8 C3F8 **TEOS** CH4 PH₃ SF₆ C2 4MS TMB+H2 SiH₂ CF4 C4F8

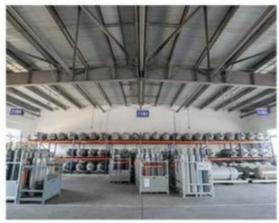
SiF4 **C3H8** CI2 C3H6 DCE BBr3

POCI3 N₂ **SO2** D+B CO+NO

SiHCI3 CH2F2 **C2H4** C2H2 HBr COS Ar+O2 HF AsH3

Xe+NO GeH4 H2Se GeCI4 **TMAI** DEZn **C2H6 B2H6** DMZn





BCI3

D2

CO₂



He +As

Ge+Se

Shanghai Kemike Chemical Co.,Ltd